



University of Michigan – Shanghai Jiao Tong University Joint Institute
Center of Optics and Optoelectronics

VE 320 – Summer 2012 Introduction to Semiconductor Device

Ideal BJT

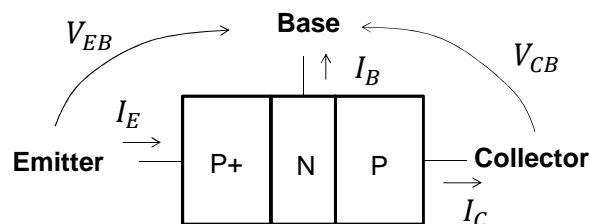
Instructor: Professor Hua Bao

NANO ENERGY LAB

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Ideal BJT



Assumptions:

- pnp device, step junction
- Steady state
- One dimensional
- Low-level injection prevails in the quasineutral regions
- No other process other than drift, diffusion, thermal R-G
- Negligible thermal R-G in depleted regions
- Emitter and collector much larger than minority carrier diffusion length

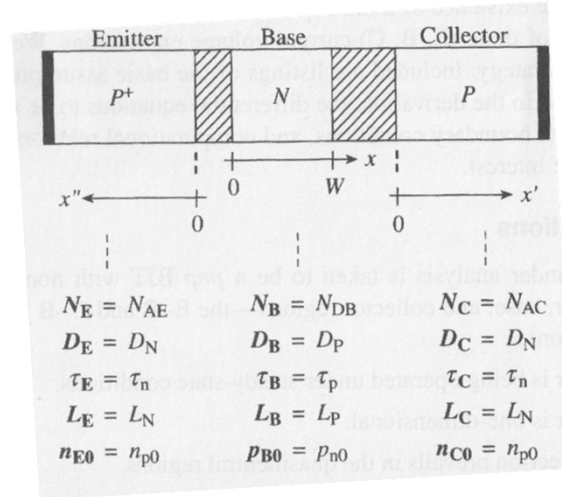


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Coordinates and Convention

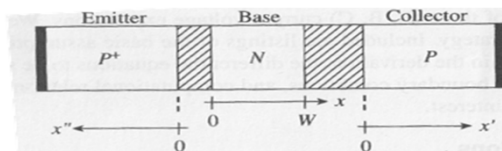


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Equations and Boundary Conditions



$$0 = D \frac{d^2 \Delta n}{dx^2} - \frac{\Delta n}{\tau} \quad \Rightarrow \quad \Delta n(x) = C_1 e^{-x/L} + C_2 e^{x/L}$$

Boundary Conditions

Emitter: $\Delta n_E(x'' \rightarrow \infty) = 0$ $\Delta n_E(x'' = 0) = n_{E0}(e^{qV_{EB}/kT} - 1)$

Base: $\Delta p_B(0) = p_{B0}(e^{qV_{EB}/kT} - 1)$ $\Delta p_B(W) = p_{B0}(e^{qV_{CB}/kT} - 1)$

Collector: $\Delta n_C(x' \rightarrow \infty) = 0$ $\Delta n_C(x' = 0) = n_{C0}(e^{qV_{CB}/kT} - 1)$



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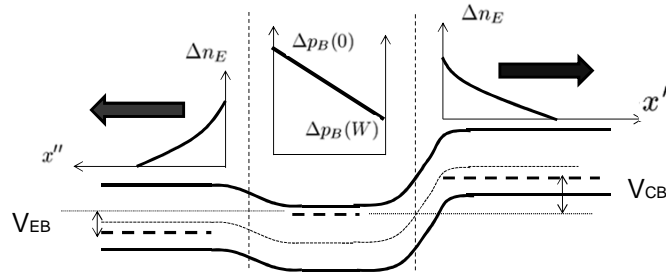
Solutions

It should not be surprising to see the solutions like the following...

$$\Delta n_E(x'') = n_{E0}(e^{qV_{EB}/kT} - 1)e^{-x''/L_E}$$

$$\Delta n_C(x') = n_{C0}(e^{qV_{CB}/kT} - 1)e^{-x'/L_C}$$

$$\Delta p_B(x) = \Delta p_B(0) \frac{\sinh[(W-x)/L_B]}{\sinh(W/L_B)} + \Delta p_B(W) \frac{\sinh(x/L_B)}{\sinh(W/L_B)}$$

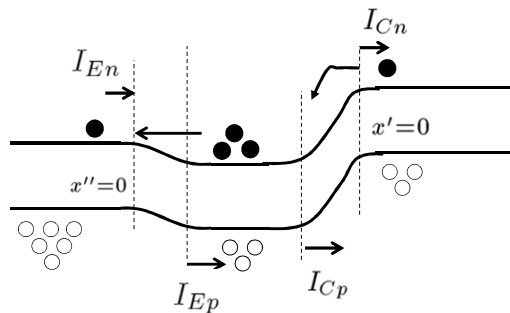


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Currents



$$I_{En} = -qAD_E \frac{d\Delta n_E}{dx''} \Big|_{x''=0} = qA \frac{D_E}{L_E} n_{E0}(e^{qV_{EB}/kT} - 1)$$

$$I_{Cn} = qAD_C \frac{d\Delta n_C}{dx'} \Big|_{x'=0} = -qA \frac{D_C}{L_C} n_{C0}(e^{qV_{CB}/kT} - 1)$$

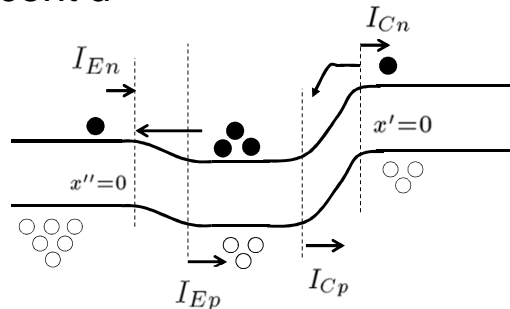


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Currents cont'd



$$I_{Ep} = qA \frac{D_B}{L_B} p_{B0} \left[\frac{\cosh(W/L_B)}{\sinh(W/L_B)} (e^{qV_{EB}/kT} - 1) - \frac{1}{\sinh(W/L_B)} (e^{qV_{CB}/kT} - 1) \right]$$

$$I_{Cp} = qA \frac{D_B}{L_B} p_{B0} \left[\frac{1}{\sinh(W/L_B)} (e^{qV_{EB}/kT} - 1) - \frac{\cosh(W/L_B)}{\sinh(W/L_B)} (e^{qV_{CB}/kT} - 1) \right]$$

Under active mode biasing, $V_{EB} > 0$ and $V_{CB} < 0$, therefore the second term is very small comparing to the first term.



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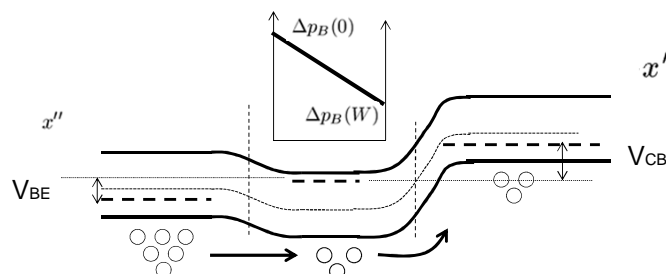
Narrow Base

$$\Delta p_B(x) = \Delta p_B(0) \frac{\sinh[(W-x)/L_B]}{\sinh(W/L_B)} + \Delta p_B(W) \frac{\sinh(x/L_B)}{\sinh(W/L_B)}$$

Base width much smaller than minority carrier diffusion length.

$$W \ll L_B$$

$$\Delta p_B(x) \approx \Delta p_B(0) \left(1 - \frac{x}{W}\right) + \Delta p_B(W) \frac{x}{W}$$



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Performance Parameters

$$\begin{aligned}\gamma &= \frac{I_{Ep}}{I_E} = \frac{I_{Ep}}{I_{Ep} + I_{En}} \\ \alpha_T &= \frac{I_{Cp}}{I_{Ep}} \\ \alpha_{dc} &= \gamma \alpha_T = \frac{I_{Cp}}{I_E} \approx \frac{I_C}{I_E} \\ \beta &= \frac{I_C}{I_B} = \frac{\alpha_{dc}}{1 - \alpha_{dc}}\end{aligned}$$

Solution of minority carrier diffusion equation
Narrow base

$$\begin{aligned}\gamma &= \frac{1}{1 + \frac{D_E N_B W}{D_B N_E L_E}} \\ \alpha_T &= \frac{1}{1 + \frac{1}{2} \left(\frac{W}{L_B} \right)^2} \\ \alpha_{dc} &= \frac{1}{1 + \frac{D_E N_B W}{D_B N_E L_E} + \frac{1}{2} \left(\frac{W}{L_B} \right)^2} \\ \beta_{dc} &= \frac{1}{\frac{D_E N_B W}{D_B N_E L_E} + \frac{1}{2} \left(\frac{W}{L_B} \right)^2}\end{aligned}$$



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Ebers-Moll Equations

$$\begin{aligned}I_E &= qA \left[\underbrace{\left(\frac{D_E}{L_E} n_{E0} + \frac{D_B}{L_B} p_{B0} \frac{\cosh(W/L_B)}{\sinh(W/L_B)} \right)}_{I_{F0}} (e^{qV_{EB}/kT} - 1) \right. \\ &\quad \left. - \underbrace{\left(\frac{D_B}{L_B} p_{B0} \frac{1}{\sinh(W/L_B)} \right)}_{\alpha_R I_{R0}} (e^{qV_{CB}/kT} - 1) \right] \\ I_C &= qA \left[\underbrace{\left(\frac{D_B}{L_B} p_{B0} \frac{1}{\sinh(W/L_B)} \right)}_{\alpha_F I_{F0}} (e^{qV_{EB}/kT} - 1) \right. \\ &\quad \left. - \underbrace{\left(\frac{D_C}{L_C} n_{C0} + \frac{D_B}{L_B} p_{B0} \frac{\cosh(W/L_B)}{\sinh(W/L_B)} \right)}_{I_{R0}} (e^{qV_{CB}/kT} - 1) \right] \\ \alpha_F I_{F0} &= \alpha_R I_{R0} = qA \frac{D_B}{L_B} \frac{p_{B0}}{\sinh(W/L_B)}\end{aligned}$$



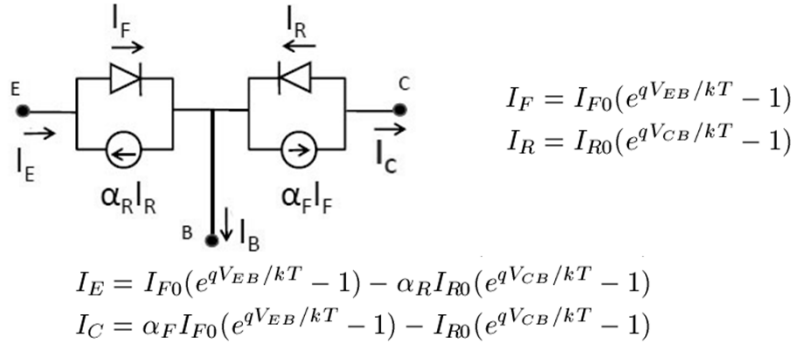
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Ebers-Moll Equations

- Node equation for BJT terminals



The four parameters can be treated as empirical parameters.



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